

April 24, 2026



Cut 8X

Growth Method	CVD
1. Hydrothermal	1. Hydrothermal
2. Sol-gel	2. Sol-gel
3. Chemical vapor deposition	3. Chemical vapor deposition
4. Physical vapor deposition	4. Physical vapor deposition
5. Atomic layer deposition	5. Atomic layer deposition
6. Electrochemical	6. Electrochemical
7. Langmuir-Blodgett	7. Langmuir-Blodgett
8. Self-assembly	8. Self-assembly
9. Spin coating	9. Spin coating
10. Dip coating	10. Dip coating
11. Inkjet printing	11. Inkjet printing
12. Spray coating	12. Spray coating
13. Layer-by-layer assembly	13. Layer-by-layer assembly
14. Molecular beam epitaxy	14. Molecular beam epitaxy
15. Pulsed laser deposition	15. Pulsed laser deposition
16. Sputtering	16. Sputtering
17. Evaporation	17. Evaporation
18. Thermal evaporation	18. Thermal evaporation
19. Electron beam evaporation	19. Electron beam evaporation
20. Thermal chemical vapor deposition	20. Thermal chemical vapor deposition
21. Plasma-enhanced chemical vapor deposition	21. Plasma-enhanced chemical vapor deposition
22. Atomic layer etching	22. Atomic layer etching
23. Inductively coupled plasma etching	23. Inductively coupled plasma etching
24. Reactive ion etching	24. Reactive ion etching
25. Deep reactive ion etching	25. Deep reactive ion etching
26. Laser etching	26. Laser etching
27. Photolithography	27. Photolithography
28. Electron beam lithography	28. Electron beam lithography
29. Ion beam lithography	29. Ion beam lithography
30. Nanoimprint lithography	30. Nanoimprint lithography
31. Soft lithography	31. Soft lithography
32. Microcontact printing	32. Microcontact printing
33. Dip pen nanolithography	33. Dip pen nanolithography
34. Scanning probe lithography	34. Scanning probe lithography
35. Laser interference lithography	35. Laser interference lithography
36. Holographic lithography	36. Holographic lithography
37. Interference lithography	37. Interference lithography
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Clouds Table, Star

Ultimate Diamond Cut Grade



P Poor **F** Fair **G** Good **VG** Very Good **EX** Excellent

Diagram illustrating the proportions and measurements of a cushion-cut diamond. The diagram shows the diamond's outline with various dimensions and percentages labeled:

- Top width: 7.73mm
- Top width percentage: 4.86mm 63%
- Top width percentage: 34.0°
- Left side height: 0.25mm 3.2%
- Left side height: 5.26mm 68.0%
- Left side angle: 38.0°
- Right side height: 0.98mm 12.5%
- Right side height: 4.03mm 52.0%
- Bottom width: 0.02mm 0.3%

DIAMOND SHAPES



CARAT WEIGHT SIZES

Carat Weight	2.50	2.00	1.50	1.00	0.75	0.50
Approx. Size						
Diameter	8.60mm	8.00mm	7.30mm	6.40mm	5.80mm	5.10mm

DIAMOND CLARITY GRADING SCALE

FL	IF	VVS1	VVS2	VS1	VS2	S11	S12	I1	I2	I3
FLAWLESS - INTERNALLY FL.		VERY VERY SLIGHTLY INCLUDED		VERY SLIGHTLY INCLUDED		SLIGHTLY INCLUDED				INCLUDED/PIQUE

DIAMOND COLOR GRADING SCALE



D - Z DIAMOND COLOR GRADING SCALE

DIAMOND FLUORESCENCE GRADING SCALE



DIAMOND POLISH & SYMMETRY GRADING SCALE

EXCELLENT	VERY GOOD	GOOD	FAIR	POOR
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BRILLIANT CUT DIAGRAM



BUY WITH
CONFIDENCE

GCAL BY SARINE™
4Cs GRADING GUARANTEE

The GCAL by Sarine™ philosophy is simple: we believe consumers should feel confident about their lab grown diamond purchase, in the same way we believe experts should be accountable and stand behind their work.

This is why your lab grown diamond is protected by a zero tolerance, money-backed grading guarantee. You should know that the GCAL by Sarine™ 4Cs Grading Certificate is the only 4Cs grading certificate in the world that comes with a guarantee that ensures the accuracy of the certified lab grown diamonds' weight and quality grades. If the carat weight or any of the cut, color, or clarity grades provided in this GCAL by Sarine™ 4Cs Grading Certificate is lower than the weight or quality grade of your certified lab grown diamond, GCAL by Sarine™ will reimburse you the difference between what you paid for the lab grown diamond and the current fair value of an equivalent lab grown diamond in the market in which it was purchased, pursuant to the newly established grades. Kindly see additional details, including the limitations of the guarantee, at GCALUSA.com.

MISSION STATEMENT

To provide the most accurate and consistent gemological grading, with uncompromising integrity and unparalleled customer service.

GEMPRINT®

Having a traceable, unique “fingerprint” of your lab grown diamond adds future protection to your investment, as well as peace of mind. GCAL by Sarine™ records the distinctive Gemprint of every diamond we certify. This patented technology for positive identification is recognized worldwide as forensic evidence and identification. Register your lab grown diamond at GEMPRINT.com

CERTIFICATE VERIFICATION

You can verify the authenticity of this certificate by entering your GCAL by Sarine™ Certificate Number at GCALUSA.com. You can also download a complimentary digital copy of this document to send to your insurance company.



GUARANTEED
CERTIFICATE



LAB GROWN



8X® is the highest achievement in precision diamond cutting. The GCAL 8X Ultimate Diamond Cut Grading System encompasses all aspects of diamond CUT quality assessment. Your lab Grown diamond has achieved grades of Excellent in all eight aspects of CUT quality assessment. As a result, this lab grown diamond is recognized for its extraordinary brilliance and beauty.

PHYSICAL EXCELLENCE

The first three of the 8X grading factors analyze the exactness of the physical surface, the facet shapes, as well as the angles. This includes the Polish, External Symmetry and Proportions.

Decades of meticulous mathematical calculations have determined the narrow proportion ranges required to produce superior cut diamonds. Each shape has been studied individually to find the most aesthetically pleasing parameters. Some of the factors considered are listed below.

To view the proportions specifications for each shape, please visit our website GCALUSA.COM

Table %	Lower Girdle Facet Length
Depth %	Star Length
Crown Angle/Height	Girdle Thickness
Pavilion Angle/Height	Culet Size

LIGHT PERFORMANCE EXCELLENCE

The next three of the 8X grading factors are Brilliance, Fire and Scintillation, which analyze the light handling ability of your lab grown diamond. The combination of these factors is the essence of what makes any diamond visibly shine, dance and sparkle from across a room. Fire and Scintillation are graded while the diamond is in motion and interacting with light. View the Fire and Scintillation videos of this lab grown diamond at GCALUSA.com or by scanning the QR code on this certificate.

OPTICAL EXCELLENCE

The last two 8X grading factors consider optical excellence. These factors scrutinize the craftsmanship, the precise alignment of the crown and pavilion facets, the shape outline, and the length to width ratio, ensuring the lab grown diamond achieves aesthetic perfection.

Grading scales for each of the 8X grading factors can be viewed at GCALUSA.com

Independently Graded and Guaranteed by GCAL by Sarine™